

Chemical bath



Contact person:

Marina Cazorla
mcazorla@ibecbarcelona.eu

Manufacturer
Quimipol

Used when substrates (e.g. silicon, metals, glass, quartz, etc.) require cleaning or chemical etching processes as part of a manufacturing procedure, for example:

- in removing the native oxides and/or organic contaminants from silicon wafers with acid, bases, solvents, etc.
- development processes of photoresins and polymers previously subjected to a curing process using UV light.

Technical specifications

- Chemical bath system with several baths built into a safety cabinet made of anti-corrosive material (polypropylene). The cabinet is a closed unit and incorporates a ventilation system.
- With the chemical bath system we can easily adapt the contents according to the requirements of the process, taking into account the polymer, resins or material to be etched.

NANOTECHNOLOGY
PLATFORM

OPPORTUNITIES FOR YOUR RESEARCH

www.ibecbarcelona.eu/corefacilities
nanotechnology@ibecbarcelona.eu